



(11)

EP 2 889 679 B1

(12)

EUROPEAN PATENT SPECIFICATION

(45) Date of publication and mention
of the grant of the patent:
29.11.2017 Bulletin 2017/48

(51) Int Cl.:
G02F 1/1339^(2006.01) G02F 1/1335^(2006.01)

(21) Application number: **14169957.9**

(22) Date of filing: **27.05.2014**

(54) **Liquid crystal display device with gap spacer and push spacer and method of fabricating the same**

Flüssigkristallanzeigevorrichtung mit Lückenabstandshalter und Druckabstandshalter und
Herstellungsverfahren dafür

Dispositif d'affichage à cristaux liquides avec écarteur et pousseur espaceur et procédé de fabrication
de celui-ci

(84) Designated Contracting States:
**AL AT BE BG CH CY CZ DE DK EE ES FI FR GB
GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO
PL PT RO RS SE SI SK SM TR**

(30) Priority: **31.12.2013 KR 20130168607**

(43) Date of publication of application:
01.07.2015 Bulletin 2015/27

(73) Proprietor: **LG Display Co., Ltd.
Seoul 150-721 (KR)**

(72) Inventors:
• **Choi, Hyongjong
Paju-si, Gyeonggi-do 413-701 (KR)**

• **Jo, Youngjik
Paju-si, Gyeonggi-do 413-779 (KR)**

(74) Representative: **Viering, Jentschura & Partner
mbB
Patent- und Rechtsanwälte
Am Brauhaus 8
01099 Dresden (DE)**

(56) References cited:
**KR-A- 20130 062 123 US-A1- 2007 069 204
US-A1- 2009 231 522 US-A1- 2012 081 640**

EP 2 889 679 B1

Note: Within nine months of the publication of the mention of the grant of the European patent in the European Patent Bulletin, any person may give notice to the European Patent Office of opposition to that patent, in accordance with the Implementing Regulations. Notice of opposition shall not be deemed to have been filed until the opposition fee has been paid. (Art. 99(1) European Patent Convention).

Description

CROSS-REFERENCE TO RELATED APPLICATIONS

[0001] The present application claims benefit and priority of Korean Patent Application No. 10-2013-0168607, filed on December 31, 2013.

BACKGROUND

1. Technical Field

[0002] The following description relates to a liquid crystal display (LCD) device with a gap spacer for maintaining the cell gap at normal condition and a push spacer (or, knocking spacer) for maintaining the cell gap when the device is pushed, and method of fabricating the same. Furthermore, the following description relates to a liquid crystal display including a first substrate including a thin film transistor and a color filter, and a second substrate including a gap spacer and a push spacer.

2. Discussion of the Related Art

[0003] A liquid crystal display (LCD) device represents video data by controlling the light transmissivity of the liquid crystal layer using the electric fields. According to the direction of the electric field, the LCD can be classified in the two major types: a vertical electric field type and a horizontal electric field type.

[0004] For the vertical electric field type LCD, the common electrode formed on the upper substrate and the pixel electrode formed on the lower substrate face each other to form the electric field having a direction perpendicular to the substrate face. The twisted nematic (TN) liquid crystal layer disposed between the upper substrate and the lower substrate is driven by the vertical electric field. The vertical electric field type LCD has an advantage of a higher aperture ratio, while it has a disadvantage of a narrower view angle of about 90° (degrees).

[0005] For the horizontal electric field type LCD, the common electrode and the pixel electrode are formed on the same substrate in parallel. The liquid crystal layer disposed between the upper substrate and the lower substrate is driven in an In-Plane-Switching (IPS) mode by the electric field that is parallel to the substrate face. The horizontal electric field type LCD has an advantage of a wider view angle over 160° (degrees) and a faster response speed than the vertical electric field type LCD. Because it often displays a better quality image, the horizontal electric field type LCD is more popular in the market.

[0006] Hereinafter, the horizontal electric field type LCD will be explained. The horizontal electric field type liquid crystal display according to the related art comprises a thin film transistor (or, TFT) array substrate, a color filter array substrate, and a liquid crystal layer inserted between these two substrates. FIG. 1 is a plane view

illustrating a thin film transistor substrate of the horizontal electric field type liquid crystal display according to the related art.

[0007] In the horizontal electric field type liquid crystal display having a thin film transistor substrate, as the pixel electrode and the common electrode are disposed apart from each other with certain distance on the same leveled plane, the video data can be represented by driving the liquid crystal using the horizontal electric field formed between these electrodes. With reference to FIG. 1, the thin film transistor substrate of the horizontal electric field type LCD panel includes a gate line GL and a data line DL crossing each other on a lower substrate, a thin film transistor T formed at the crossing portion of the gate line GL and the data line DL, a pixel electrode PXL and a common electrode COM formed within a pixel area defined by the crossing structure of the gate line GL and the data line DL to form a horizontal electric field, and a common line CL connecting to the common electrode and running parallel with the gate line GL.

[0008] The gate line GL supplies the gate signal to the gate electrode G of the thin film transistor T. The data line DL supplies the pixel signal to the pixel electrode PXL through the drain electrode D of the thin film transistor T. The gate line GL and the data line DL are formed in the crossed structure to define the pixel area. The common line CL is formed to be parallel to the gate line GL at one side of the pixel area, and supplies the reference voltage signal for driving the liquid crystal layer to the common electrode.

[0009] The thin film transistor T charges and maintains the pixel signal voltage to the pixel electrode PXL by responding to the gate signal of the gate line GL. To do so, the thin film transistor T includes a gate electrode G connected to the gate line GL, a source electrode S connected to the data line DL, and a drain electrode D connected to the pixel electrode PXL. Further, the thin film transistor T may include an active channel layer (not shown) between the source electrode S and the drain electrode D, and an ohmic contact layer (not shown) for keeping the ohmic contact with the source electrode S and the drain electrode D.

[0010] The pixel electrode PXL is formed within the pixel area to be connected to the drain electrode D of the thin film transistor T, and exposed via a drain contact hole DH formed through the passivation layer (not shown). Especially, the pixel electrode PXL includes a horizontal pixel electrode PXLh connected to the drain electrode D and is parallel to the neighboring gate line GL, and a plurality of vertical pixel electrodes PXLv branched from the horizontal pixel electrode PXLh that extend in the vertical direction within the pixel area.

[0011] The common electrode is connected to the common line CL via a common contact hole CH formed through the gate insulating layer, the passivation layer, and the planarization layer. Some portions of the common electrode that are parallel with the gate line GL having wider width may be a horizontal common electrode

COMh. Further, the common electrode includes a plurality of vertical common electrode COMv branched from the horizontal common electrode COMh and extended in the vertical direction within the pixel area. Especially, the vertical pixel electrode PXLv and the vertical common electrode COMv are disposed in parallel with each other within the pixel area.

[0012] Therefore, the horizontal electric field is formed between the vertical pixel electrode PXLv supplied with the pixel signal voltage through the thin film transistor T and the vertical common electrode COMv supplied with the reference signal voltage through the common line CL. Due to this horizontal electric field, the liquid crystal molecules of the liquid crystal layer disposed between the thin film transistor array substrate and the color filter substrate are rotated by the dielectric anisotropy. Based on the rotating amount, the light transmittance of the pixel area is altered, and then the video image can be represented.

[0013] The thin film transistor substrate is joined with the color filter substrate with the liquid crystal layer therebetween. Here, in order to keep the gap between the thin film transistor substrate and the color filter substrate uniform, a plurality of gap column spacer GCS may be disposed on the inner surface of the color filter substrate. The gap column spacer GCS may be formed to overlap with the non-open area (to not allow the light to pass) where the lines and/or the thin film transistor is formed.

[0014] On the overall area of the liquid crystal display, the gap column spacers GSC would be disposed as being scattered with a proper distribution density. FIG. 2 is a plane view illustrating a distribution of the gap column spacers in the liquid crystal display according to the related art. With reference to FIG. 2, the liquid crystal display includes a plurality of unit pixels disposed in a matrix manner, where each unit pixel has a group of subpixels including a red subpixel, a green subpixel, and a blue subpixel. For example, the red color filters CFR allocated at red subpixels may be disposed along one column, and the green color filters CFG may be disposed along the next column. Further, the blue color filters CFB may be disposed along the next column after the green color filters CFG.

[0015] With this pixel array structure, the liquid crystal layer is sandwiched between the thin film transistor substrate and the color filter substrate. A plurality of the gap column spacers GCS are distributed with the liquid crystal layer for maintaining the thickness of the liquid crystal layer (i.e., Cell Gap) in even or uniform condition. FIG. 2 shows an example distribution of the gap column spacers in which four (4) gap column spacers are evenly distributed within a 25 x 9 pixel array.

[0016] Due to the gap column spacer GCS, the thickness between the thin film transistor substrate and the color filter substrate can be maintained in an even and/or uniform condition. However, when a touch panel has been applied to the liquid crystal display, a user may frequently press the surface of the liquid crystal display. In

this case, at the area where there is no gap column spacer GCS, the cell gap may not be maintained in uniform condition due to the pressing force of the user's finger (the "touch pressure"). As this touch pressure is not always the same, the cell gap may be severely thinned when the user touches the display surface with a strong pressing force. When these touches are frequently repeated, the display quality may have any unexpected problem or may be damaged.

[0017] Therefore, with the exception of the gap spacer for keeping the cell gap in uniform condition, it is desirable to have a means or structure to prevent the cell gap from being severely thinned when the user presses/touches the display surface.

[0018] Patent document US 2012/0081640 A1 describes a liquid crystal display device comprising a first substrate, a second substrate and a liquid crystal layer disposed between the first substrate and the second substrate. Pixel electrodes are formed on color filters on pixel regions on the first substrate. A common electrode is formed on the entire surface of the second substrate. A contact hole contacts a pixel electrode with a thin film transistor. Main column spacers formed on the second substrate are shown in Figures 2, 4 and 6 as extending up to the first substrate. Other spacers formed on the second substrate appear to be separated from the first substrate. The main column spacers and the other column spacers may have a height difference S1 of about 0.4 μm to about 0.5 μm . Step patterns ("mesas") disposed on the first substrate correspond to the other spacers and are patterned such that the stepped patterns do not overlap and disturb formation of the contact holes.

[0019] Patent document US 2009/0231522 A1 describes a liquid crystal display panel with a first substrate, a second substrate and an interposed liquid crystal layer. The first substrate includes a color filter layer covering pixel regions and thin film transistors TFT. Pixel electrodes are formed on the color filter layer and electrically connected to the TFT through a contact hole that is perforated through the color filter layer. The second substrate includes a common electrode. The second substrate further includes a first spacer and a second spacer. When the first substrate and the second substrate are combined or coupled, the first spacer makes contact with the first substrate, whereas, to distribute the liquid crystal molecules, the second spacer may be spatially separated from the first substrate by a predetermined distance when the first substrate and the second substrate are combined or coupled.

[0020] Patent document US 2007/0069204 A1 describes an LCD panel including a first substrate, a second substrate opposite to the first substrate, a column spacer assembly maintaining a constant cell gap between the first and second substrates, and a liquid crystal layer interposed between the first and second substrates. A red color filter layer, a green color filter layer and a blue color filter layer are alternately formed in each pixel region of the first substrate. The red color filter layer and a green

color filter layer overlap each other on a thin film transistor. The column spacer assembly includes a main column spacer and a sub column spacer, which are substantially equal in length. The main column spacer includes a first end connected to the green color filter layer on the thin film transistor of the first substrate, and a second end connected to a black matrix of the second substrate. Only the main column spacer has both ends connected to the first and second substrates, whereas the sub column spacer includes a second end spaced apart from the first substrate. When external force is applied to the LCD panel, the second end of the sub column spacer comes into contact with a recessed portion of the first substrate. When this happens, the sub column spacer as well as the main column spacer may become connected to both the first and second substrates. Accordingly, both the sub column spacer and the main column spacer may receive the pressure applied to the LCD panel, so that the pressure may be effectively dispersed and distributed by the column spacer assembly. Thus, the column spacer assembly may prevent external forces from damaging the color filter layer or the black matrix.

[0021] Patent document KR-10-2013-0062123 relates to an IPS-type LCD device comprising a color-filter-on-array type of TFT substrate and two kinds of spacers having different heights. Two separate contact hole areas are provided in each subpixel, and individual color filter layers do not overlap in a pixel.

SUMMARY

[0022] Accordingly, embodiments of the present application are directed to a liquid crystal display (LCD) device with a gap spacer and a push spacer, and a method of fabricating the same, that substantially obviates one or more problems due to the limitations and disadvantages of the related art.

[0023] An object of embodiments is to provide a liquid crystal display having a gap spacer for keeping the cell gap and a push spacer for preventing the cell gap from being thinned severely as the display is pressed. In particular, embodiments of the present invention make it possible to obtain more space to dispose the gap column spacers and/or the push column spacers. Another object of embodiments is to provide a liquid crystal display including a push spacer including a height lower than that of the gap spacer. Still another object of embodiments is to provide a liquid crystal display including a lower substrate including a thin film transistor and a color filter, and an upper substrate including a gap spacer and a push spacer.

[0024] Advantages, objects, and features of the disclosure will be set forth in part in the description which follows and in part will become apparent to those having ordinary skill in the art upon examination of the following or may be learned from practice of the invention. The objectives and other advantages of the invention may be realized and attained by the structure particularly pointed out in

the written description and claims hereof as well as the appended drawings.

[0025] To achieve these objects and other advantages and in accordance with the purpose according to one aspect of the invention, there is provided a liquid crystal display device as in claim 1.

[0026] In one or more embodiments, a distance between two neighboring contact hole areas is 35~50 μm (micrometers); and the push column spacer is disposed between the two neighboring contact hole areas.

[0027] In one or more embodiments, an upper surface of the gap column spacer contacts a top inner surface of the lower substrate; and an upper surface of the push column spacer is separated from the top inner surface of the lower substrate by 600 ~ 700 nm.

[0028] In one or more embodiments, the gap column spacer has a first height; the push column spacer has a second height 300 ~ 400 nm less than the first height; and at the non-aperture area, a first stacked height of a first overlap area of the first color filter and the second color filter, corresponding to the push column spacer, is 200 ~ 300nm less than a second stacked height of a second overlap area of the first color filter and the second color filter, corresponding to the gap column spacer.

[0029] In one or more embodiments, the lower substrate further comprises a third color filter disposed at an aperture area of a third subpixel; the first color filter comprises a red color filter; the second color filter comprises a blue color filter; and the third color filter comprises a green color filter.

[0030] In one or more embodiments, the non-aperture area of the lower substrate further comprises: a gate line and a common line disposed in a first direction of the lower substrate; a data line disposed in a second direction of the lower substrate; and a thin film transistor connected to the gate line and the data line; and the aperture area of the lower substrate further comprises: a pixel electrode connected to the thin film transistor and comprising a plurality of segments separated from each other; and a common electrode comprising a plurality of segments parallel to each segment of the pixel electrode.

[0031] In one or more embodiments, the contact hole area comprises a drain contact hole connecting the thin film transistor to the pixel electrode.

[0032] In one or more embodiments, the contact hole area comprises a common contact hole connecting the common electrode to the common line.

[0033] In one or more embodiments, the upper substrate further comprises a black bezel surrounding the upper substrate at the outermost edge; and the gap column spacer and the push column spacer comprise a same material as the black bezel.

[0034] In another aspect, there is provided a method of manufacturing a liquid crystal display device as in claim 8.

[0035] In one or more embodiments, a distance between two neighboring contact hole areas is 35~50 μm (micrometers); and the push column spacer is provided

between the two neighboring contact hole areas.

[0036] In one or more embodiments, an upper surface of the gap column spacer is provided to contact a top inner surface of the lower substrate; and an upper surface of the push column spacer is provided to be separated from the top inner surface of the lower substrate by 600 ~ 700 nm.

[0037] In one or more embodiments, the gap column spacer has a first height; the push column spacer has a second height 300 ~ 400 nm less than the first height; and at the non-aperture area, a first stacked height of a first overlap area of the first color filter and the second color filter, corresponding to the push column spacer, is 200 ~ 300 nm less than a second stacked height of a second overlap area of the first color filter and the second color filter, corresponding to the gap column spacer.

[0038] In one or more embodiments, providing the lower substrate further comprises providing a third color filter disposed at an aperture area of a third subpixel; providing the first color filter comprises providing a red color filter; providing the second color filter comprises providing a blue color filter; and providing the third color filter comprises providing a green color filter.

[0039] In one or more embodiments, providing the non-aperture area of the lower substrate further comprises: providing a gate line and a common line in a first direction of the lower substrate; providing a data line in a second direction of the lower substrate; and providing a thin film transistor connected to the gate line and the data line; and providing the aperture area of the lower substrate further comprises: providing a pixel electrode connected to the thin film transistor and comprising a plurality of segments separated from each other; and providing a common electrode comprising a plurality of segments parallel to each segment of the pixel electrode.

[0040] In one or more embodiments, providing the contact hole area comprises providing a drain contact hole connecting the thin film transistor to the pixel electrode.

[0041] In one or more embodiments, providing the contact hole area comprises providing a common contact hole connecting the common electrode to the common line.

[0042] In one or more embodiments, providing the upper substrate further comprises providing a black bezel surrounding the upper substrate at the outermost edge; and the gap column spacer and the push column spacer comprise a same material as the black bezel.

[0043] Other systems, methods, features and advantages will be, or will become, apparent to one with skill in the art upon examination of the following figures and detailed description. Further aspects and advantages are discussed below in conjunction with the embodiments. It is to be understood that both the foregoing general description and the following detailed description of the present disclosure are exemplary and explanatory and are intended to provide further explanation of the disclosure as claimed.

BRIEF DESCRIPTION OF THE DRAWINGS

[0044] The accompanying drawings, which are included to provide a further understanding of the invention and are incorporated in and constitute a part of this specification, illustrate implementations of the invention and together with the description serve to explain the principles of the invention.

FIG. 1 is a plane view illustrating the thin film transistor substrate of a horizontal electric field type liquid crystal display according to the related art.

FIG. 2 is a plane view illustrating a distribution of the gap column spacers in the liquid crystal display of FIG. 1.

FIG. 3 is a plane view illustrating a structure of a liquid crystal display according to related art, useful for the understanding of the present invention.

FIG. 4 is a cross-sectional view, along line I-I' of FIG. 3, illustrating a structure of a gap spacer and a push spacer in a liquid crystal display according to related art, useful for the understanding of the present invention.

FIG. 5 is a plane view illustrating an example distribution of a plurality of the gap spacers and a plurality of the push spacers in a liquid crystal display according to an embodiment.

FIG. 6 is a plane view illustrating a structure of a liquid crystal display according to an embodiment.

FIG. 7 is a plane view illustrating a structure of color filter array in a liquid crystal display according to an embodiment.

FIG. 8 is a cross-sectional view, along line II-II' of FIG. 6, illustrating a structure of a gap spacer and a push spacer in a liquid crystal display according to an embodiment.

[0045] Throughout the drawings and the detailed description, unless otherwise described, the same drawing reference numerals should be understood to refer to the same elements, features, and structures. The relative size and depiction of these elements may be exaggerated for clarity, illustration, and convenience.

DETAILED DESCRIPTION

[0046] Reference will now be made in detail to embodiments of the present invention, examples of which are illustrated in the accompanying drawings. In the following description, when a detailed description of well-known functions or configurations related to this document is

determined to unnecessarily cloud a gist of the invention, the detailed description thereof will be omitted. The progression of processing steps and/or operations described is an example; however, the sequence of steps and/or operations is not limited to that set forth herein and may be changed as is known in the art, with the exception of steps and/or operations necessarily occurring in a certain order. Like reference numerals designate like elements throughout. Names of the respective elements used in the following explanations are selected only for convenience of writing the specification and may be thus different from those used in actual products.

[0047] In the description of embodiments, when a structure is described as being positioned "on or above" or "under or below" another structure, this description should be construed as including a case in which the structures contact each other as well as a case in which a third structure is disposed therebetween.

[0048] Hereinafter, embodiments will be described in detail with reference to the accompanying drawings.

[0049] FIG. 3 is a plane view illustrating a structure of a liquid crystal display according to related art, useful for the understanding of the present invention. FIG. 4 is a cross-sectional view, along line I-I' of FIG. 3, illustrating a structure of a gap spacer and a push spacer in a liquid crystal display according to related art, useful for the understanding of the present invention. FIG. 5 is a plane view illustrating an example distribution of a plurality of the gap spacers and a plurality of the push spacers in a liquid crystal display according to an embodiment.

[0050] In FIG. 3, two neighboring pixel areas are shown in the drawing. Structures of the liquid crystal display in FIG. 3 that are similar to those of FIG. 1 may not be explained in detail. The explanation may be focused on the main features of embodiments of the present invention, especially the gap column spacer GCS and the push column spacer PCS. With reference to FIG. 3, the liquid crystal display according to related art, useful for the understanding of the present invention may include a gap column spacer GCS for keeping the cell gap in uniform condition. Further, it may include a push column spacer PCS for preventing the cell gap from being severely thinned by the pressing force when user touches or presses the surface of the liquid crystal display.

[0051] With reference to FIG. 4, the structure of the gap column spacer GCS and the push column spacer PCS will be explained. A gate line GL and a horizontal common electrode COMh may be provided on the lower substrate SL. A gate insulating layer GI may be provided on the gate line GL and the horizontal common electrode COMh. A data line DL may be provided on the gate insulating layer GI to cross with the gate line GL. A passivation layer PAS may be provided on the data line DL to cover an entire surface of the lower substrate SL.

[0052] The lower substrate may face with and may be joined with the upper substrate SU, and a liquid crystal layer LC may be disposed between the lower and the upper substrates. A black matrix BM may be formed on

the upper substrate SU for defining the pixel areas. Within each of the pixel areas defined by the black matrix BM, a color filter may be formed. For example, for one pixel area, a red color filter CFR may be formed. A green color filter CFG (or a blue color filter CFB) may be formed at another pixel area neighboring to the red pixel area. An overcoat layer OC may be deposited on the color filters to cover an entire surface of the upper substrate SU.

[0053] On the overcoat layer OC of the upper substrate SU, there may be disposed a gap column spacer GCS for maintaining the cell gap in a uniform condition and a push column spacer PCS for preventing the cell gap from being severely thinned when the upper substrate SU is pressed and/or touched. The gap column spacer GCS may have a first height corresponding to the cell gap, which may be the properly designed distance between the upper substrate SU and the lower substrate SL. The push column spacer PCS may have a second height slightly lower than the first height of the gap column spacer GCS. In other words, the upper surface of the gap column spacer GCS may contact on the top inner surface of the lower substrate SL. In one example, the upper surface of the push column surface PCS may be spaced apart from the top inner surface of the lower substrate SL by a predetermined distance.

[0054] For example, the upper surface of the push column spacer PCS may be separated by about 600 ~ 700nm from the top inner surface of the lower substrate SL. In one example, when the push column spacer PCS and the gap column spacer GCS are formed near to each other, the height difference ΔH of the first height of the gap spacer GCS and the second height of the push column spacer PCS may be about 600 ~ 700 nm.

[0055] As the gap column spacer GCS may maintain the cell gap between the upper substrate SU and the lower substrate SL, the distribution (e.g., scattering) density of the gap column spacer GCS may not be a high value. Rather, the size of the gap column spacer GCS may be designed to ensure sufficient strength. Meanwhile, the push column spacer PCS may sustain the cell gap such that it is not severely thinned when the upper substrate SU and the lower substrate SL are pressed/touched to be close each other. Therefore, in one example, the distribution density of the push column spacer PCS may have as high a value as possible. If the push column spacer PCS is designed to have a similar size as that of the gap column spacer GCS, the area occupying ratio (ratio of the total cross-sectional area of the all spacers) of the push column spacer PCS may be larger. This may cause undesirable effects in the display. Therefore, in one example, the push column spacer PCS may be designed to have a smaller size than the gap column spacer GCS.

[0056] For example, when the gap column spacer GCS is designed in a truncated cone shape (as illustrated in the FIG. 4 example), the cross-sectional diameter of the lower surface contacting to top inner surface of the upper substrate SU may be about 31.5 μm (micrometers), and

the cross-sectional diameter of the upper surface contacting to top inner surface of the lower substrate SL may be 15.4 μm (micrometers). Furthermore, when the push column spacer PCS is designed in a truncated cone shape (as illustrated in the FIG. 4 example), the cross-sectional diameter of the lower surface contacting to top inner surface of the upper substrate SU may be about 29.8 μm (micrometers), and the cross-sectional diameter of the upper surface contacting to top inner surface of the lower substrate SL may be 17.5 μm (micrometers). Because the height of the push column spacer PCS may be lower than that of the gap column spacer GCS, the cross-sectional diameter of the push column spacer PCS may be

cross-sectional diameter of the lower surface of the spacers, and the dot circle represents the cross-sectional diameter of the upper surface of the spacers.

[0057] With reference to FIG. 5, an example for the distribution of the gap column spacer GCS and the push column spacer PCS is described. For the liquid crystal display, a plurality of unit pixels may be disposed in a matrix manner, wherein each of unit pixels may have three subpixels including a red subpixel, a green subpixel, and a blue subpixel. For example, the red color filters CFR allocated at red subpixels may be disposed along one column, and the green color filters CFG may be disposed along the next column. Further, the blue color filters CFB may be disposed along the next column after the green color filters CFG.

[0058] With this pixel array structure, the liquid crystal layer LC (FIG. 4) may be sandwiched between the lower substrate SL including the thin film transistor and the pixel electrode and the upper substrate SU including the color filter. A plurality of the gap column spacers GCS may be distributed with the liquid crystal layer LC for maintaining the thickness of the liquid crystal layer (e.g., a "cell gap") in an even or uniform condition over the entire surface of the display panel. FIG. 5 shows an example distribution of the gap column spacers in which, for example, four (4) gap column spacers GCS may be evenly distributed within a 25 x 9 pixel array. That is, the distribution of the gap column spacer GCS according to an embodiment may be similar to the distribution according to the related art. Further, the liquid crystal display according to an embodiment may include, for example, thirty-six (36) push column spacers PCS within a 25 x 9 pixel array.

[0059] In the liquid crystal display according to an embodiment as shown in the examples in FIGs. 3 and 4, the thin film transistor may be formed on the lower substrate SL, and the color filter may be formed on the upper substrate SU. The gap column spacer GCS and the push column spacer may be formed at the area where the black matrix BM may be formed. As the black matrix BM made of untransparent resin material may also be formed between each color filter, the gap column spacer GCS and the push column spacer PCS may be made of a transparent resin material. In one example, even though they may have different heights, the gap column spacer GCS

and the push column spacer PCS may be formed at the same time with a half-tone mask. When a transparent resin material is patterned with a half-tone mask, the height difference of 600 ~ 700 nm between the gap column spacer GCS and the push column spacer PCS may be easily ensured.

[0060] In one embodiment, in order to simplify the manufacturing process for the liquid crystal display, the color filter may be formed at the lower substrate with the thin film transistor. In one example, there may be no black matrix on the upper substrate SU, but only the gap column spacer GCS and the push column spacer PCS may be formed on the transparent upper substrate SU. For example, for the ultra high resolution liquid crystal display including greater than 300 ppi, many other things may be considered.

[0061] As shown in the FIG. 3 example, in a liquid crystal display including less than 200 ppi resolution, there may be no problem with distributing the gap column spacer GCS and the push column spacer PCS on the area of the gate line GL disposed between each of the pixel rows. However, in an ultra high density used liquid crystal display including less than 300 ppi resolution, the area of the unit pixel may be much smaller. As a result, the distance between the drain contact hole DH and the common contact hole CH may decrease. For the ultra high density liquid crystal display with greater than 300 ppi resolution, it may be difficult to maintain the distance between the contact holes with 32 μm (micrometers) or more. Therefore, it may be difficult to distribute any one of the gap column spacer GCS and the push column spacer PCS between the contact holes in a stable condition.

[0062] For example, for the gap column spacer GCS including a lower distribution density, even if it is disposed as overlapping somewhat with the pixel area neighboring the gate line GL area, it may not cause an issue with the brightness or luminescence. However, for the push column spacer PCS including a higher distribution density than that of the gap column spacer GCS, when it is disposed as overlapping with the pixel area, it may cause a reduction of the aperture ratio. As the pixel resolution increases, the pixel size decreases. Therefore, as the push column spacer PCS reduces the aperture ratio, it may also cause severe deterioration of the display quality.

[0063] Hereinafter, according to an embodiment, there is described an example in which the color filter may be formed on the lower substrate with the thin film transistor in the ultra high density liquid crystal display including greater than 300 ppi resolution, and the gap column spacer GCS and the push column spacer PCS may be effectively disposed. FIG. 6 is a plane view illustrating a structure of a liquid crystal display according to an embodiment. FIG. 7 is a plane view illustrating a structure of color filter array in a liquid crystal display according to an embodiment. FIG. 8 is a cross-sectional view, along the line 11-11' of FIG. 6, illustrating a structure of a gap spacer

er and a push spacer in a liquid crystal display according to an embodiment.

[0064] With reference to FIGs. 6 and 8, the liquid crystal display according to the second embodiment of the present disclosure may have a lower substrate SL having a thin film transistor T. On the thin film transistor, a passivation layer PAS is deposited as covering the whole surface of the lower substrate SL. On the passivation layer PAS, a color filter may be formed within a pixel area. For example, the red color filters CFR allocated at red subpixels may be disposed along one column, and the green color filters CFG may be disposed along the next column. Further, the blue color filters CFB may be disposed along the next column after the green color filters CFG.

[0065] A plurality of pixel areas may be defined as being disposed in a matrix manner on the lower substrate SL. A thin film transistor T may be disposed on one side within a pixel area. A pixel electrode PXL connected to the thin film transistor T may be formed within the aperture area of the pixel area. For the horizontal electric field type, the pixel electrode PXL may include a plurality of vertical pixel electrodes PXLv having a segment shape, disposed parallel to one another, and separated from each other by a predetermined distance. The pixel electrode PXL may also include a horizontal pixel electrode PXLh connecting all of the vertical pixel electrodes PXLv. Further, a plurality of vertical common electrodes COMv, parallel with each of the horizontal pixel electrodes PXLv, may be formed within the pixel area.

[0066] On the upper surface of the lower substrate SL including the thin film transistor T, the pixel electrode PXL, and the common electrode COM, and a passivation layer PAS may be deposited to cover an entire surface of the lower substrate SL. On the passivation layer PAS, a plurality of color filters CFR, CFG, CFB may be formed such that each color filter may be allocated to each pixel area. On the upper surface of the lower substrate SL including the color filter, a planarization layer PAC may be deposited to cover the entire surface of the lower substrate SL.

[0067] In an example in which the color filter is formed on the lower substrate SL, in order to simplify the manufacturing method, the black matrix BM may not be formed. Instead of the black matrix BM, two or more color filters may be overlapped to block the light leakage by forming a stack structure. For example, at an area where the black matrix may be desired, the red color filter CFR and the blue color filter CFB may be stacked to form a substitute for the black matrix BM.

[0068] For one example, the red color filter CFR, the green color filter CFG, and the blue color filter CFB may be stacked to form a substitute for the black matrix BM. However, this three layer stacked structure may cause severe level differences, and may cause other side effects. Therefore, embodiments may include forming a substitute for the black matrix BM by stacking any two color filters among the red, the green, and the blue color

filters. In one example, in order to obtain a function closer to that of the black matrix BM, the red-blue combination may provide a better result, among the red-green, the green-blue, and the red-blue combinations.

[0069] For example, as shown in FIG. 7, at first, the red color filter CFR may be formed. The red color filter CFR may be formed over the area where the red pixel area and the black matrix area are located. Here, the "red pixel area" corresponds to an aperture area of a pixel area for representing a red color. The "line area" corresponds to the non-aperture area surrounding the aperture area in the pixel area. In FIG. 7, the inner area surrounded by the solid line may be the area where the red color filter CFR is formed. The area for the red color filter CFR is illustrated in FIG. 7 as an upper right to lower left diagonal hatch pattern.

[0070] After that, the blue color filter CFB may be formed. In one example, the blue color filter CFB may be formed to cover the blue pixel area and all of the non-aperture area where the black matrix is desired. For instance, where the red color filter and the blue color filter are overlapped, in one example, the blue color filter CFB may be wider than the red color filter CFR. As a result, as shown in FIG. 8, at the non-aperture area where the black matrix is desired, the blue color filter CFB may perfectly cover or may overspread the red color filter CFR. In the FIG. 7 illustration, the inner area surrounded by the bold solid line is the area where the blue color filter CFB is formed. The area for blue color filter CFB is illustrated as a upper left to lower right diagonal hatch pattern.

[0071] Therefore, at the non-aperture area where the black matrix is formed in the related art - especially, where the gate line GL, the common line CL, and the thin film transistor T are formed - the red color filter CFR and the blue color filter CFB are deposited. In the FIG. 7 example, the non-aperture area is represented as having two hatch patterns for red color filter CFR and the blue color filter CFB at the same time (e.g., where the different-directioned lines cross).

[0072] In addition, in one embodiment, the green color filter CFG may be formed only at the green pixel area. In the FIG. 7 illustration, the area having no hatch pattern represents the area for the green color filter CFG. Here, at the contact hole area CA, there may be no color filter deposited.

[0073] In the liquid crystal display according to an embodiment, the gap column spacer GCS and the push column spacer PCS may be formed at an area of the upper substrate SU corresponding to an area where the red color filter CFR and the blue color filter CFB are formed to overlap. As explained above, in the case of the ultra high density liquid crystal display greater than 300 ppi resolution as shown in FIG. 6, the size of the unit pixel may decrease. Further, the distance between the drain contact hole DH and the common contact hole CH may decrease.

[0074] However, as shown in FIG. 6, by disposing the drain contact hole DH and the common contact hole CH

closer to each other, these two contact holes DH and CH may be disposed within one contact area CA. As a result, the distance between neighboring two contact area CA may be greater than 32 μm (micrometers), e.g., 35 ~ 50 μm (micrometers). Therefore, it may be possible to obtain enough space to dispose the gap column spacer GCS and/or the push column spacer PCS between two neighboring contact areas CA.

[0075] In addition, there may be a height difference between the gap column spacer GCS and the push column spacer PCS. That is, in an embodiment in which the color filter is formed on the lower substrate SL with the thin film transistor, the following condition may be considered.

[0076] In one embodiment, the gap column spacer GCS and the push column spacer PCS may be formed on the upper substrate SU. As mentioned above, two color filters may be overlapped to form a substitute for the black matrix BM of the FIG. 4 example; therefore, the upper substrate SU in the FIG. 8 example may not include the black matrix. However, at a bezel area surrounding the upper substrate SU at an outermost boundary, a black resin material may be deposited and patterned to form a black bezel. In order to simplify the manufacturing process, the gap column spacer GCS and the push column spacer PCS may be formed with the black bezel.

[0077] For example, a black resin material may be deposited on the inner surface of the upper substrate SU, and then the gap column spacer GCS having the first height and the push column spacer PCS having the second height may be formed using one half-tone mask. The black bezel may have any height that is the same as that of the gap column spacer GCS or the push column spacer PCS. However, when the half-tone mask process is applied to the black resin material, it may be difficult to obtain a precisely desired height difference ΔH between the first height and the second height, e.g., 600 ~ 700 nm.

[0078] When depositing a black resin material and then patterning the gap column spacer GCS and the push column spacer PCS at the same time using the half-tone mask, the possible height difference may be 300 ~ 400 nm, at most. Therefore, it may be desirable to achieve an additional 200 ~ 400 nm of the height difference to reach the desired 600 ~ 700 nm total desired height difference ΔH .

[0079] As mentioned above with respect to the FIG. 6 example, this problem may be solved by changing the structure such that the drain contact hole DH and the common contact hole CH may be disposed much closer, such that one contact area CA has the two contact holes. The solution may be obtained as follows. The total height (or, thickness) of the stacked red color filter CFR and the blue color filter CFB at the area between the two neighboring contact hole area CA may be about 200 ~ 300 nm less (e.g., lower or thinner) than the total height of the stacked color filter deposited at the other areas.

[0080] By the separation distance between the two neighboring contact hole areas CA to be less than 50 μm

(micrometers), the thickness of the stacked red color filter CFR and the blue color filter CFB at the area between the two neighboring contact hole areas CA may be thinner than other areas further from the contact hole area CA. This thinned amount of the thickness may be controlled by adjusting the separation distance between the two neighboring contact hole areas CA. Further, with this structure, it may be possible to maintain the contact hole area separation distance to be more than 35 μm (micrometers), even if the display panel has a 300 ppi or higher resolution density. Therefore, by controlling the separation distance of the neighboring contact hole areas CA within the range of 35 ~ 50 μm (micrometers), the required additional height difference between the gap column spacer GCS and the push column spacer PCS may be compensated.

[0081] For example, the push column spacer PCS may be disposed between the two neighboring contact hole areas CA, and the gap column spacer GCS may be disposed on the gate line GL where there is no contact area CA nearby. As a result, the push column spacer PCS and the gap column spacer GCS formed on the upper substrate SU using the half-tone mask may have the first height difference ΔH_1 , e.g., 300 ~ 400 nm. That is, the height difference between the top surface of the push column spacer PCS and the top surface of the gap column spacer GCS may be the first height difference ΔH_1 , e.g., 300 ~ 400 nm.

[0082] In addition, the second height difference ΔH_2 , e.g., 200 ~ 300 nm, may be further ensured by the thickness difference between the thickness of stacked red color filter CFR and the blue color filter CFB deposited at the between area of the two neighboring contact hole areas CA and the thickness of the stacked red color filter CFR and the blue color filter CFB deposited further from the contact hole area CA. As a result, the desired total height difference ΔH of 600 ~ 700 nm may be achieved between the upper surface of the push column spacer PCS and upper surface of the lower substrate SL.

[0083] In an embodiment, even though the actual height difference between the push column spacer PCS and the gap column spacer GCS may not be sufficient, the separation distance of the push column spacer PCS from the upper surface of the lower substrate SL may be obtained by controlling the thickness of the color filter(s) according to the deposited position of the spacers on the lower substrate SL. For example, by controlling the distance between two neighboring contact hole areas CA within 35 ~ 50 μm (micrometers), the stacked thickness of the color filters on the non-aperture area between the two neighboring contact hole areas may be controlled to be different from the stacked thickness of the color filters on the non-aperture area further from the contact hole area CA. Therefore, without any specially added mask process, the height difference of the push column spacer PCS may be exactly controlled.

[0084] In one embodiment, a predetermined distance between two neighboring contact hole areas is 35~50

μm (micrometers), and the push column spacer may be disposed between the two neighboring contact hole areas.

[0085] In one embodiment, an upper surface of the gap column spacer may contact a top inner surface of the lower substrate, and an upper surface of the push column spacer may be separated by 600 ~ 700 nm from the top inner surface of the lower substrate.

[0086] In one embodiment, the gap column spacer may have a first height, the push column spacer may have a second height 300 ~ 400 nm less than the first height, and a first stacked height of the first color filter, and the second color filter overlapped at the non-aperture area corresponding to the push column spacer may be 200 ~ 300 nm less than a second stacked height of the first color filter and the second color filter at the non-aperture area corresponding to the gap column spacer.

[0087] In one embodiment, the lower substrate may include a third color filter disposed at the aperture area of a third subpixel, the first color filter may be a red color filter, the second color filter may be a blue color filter, and the third color filter may be a green color filter.

[0088] In one embodiment, the non-aperture area of the lower substrate may include: a gate line and a common line running to a first direction of the lower substrate, a data line running to a second direction of the lower substrate, and a thin film transistor connected to the gate line and the data line. The aperture ratio of the lower substrate may further include: a pixel electrode connecting to the thin film transistor and including a plurality of segments separated from each other, and a common electrode including a plurality of segments parallel to the each segment of the pixel electrode.

[0089] In one embodiment, the contact hole area may include a drain contact hole connecting the thin film transistor to the pixel electrode.

[0090] In one embodiment, the contact hole area may include a common contact hole connecting the common electrode to the common line.

[0091] In one embodiment, the upper substrate may include a black bezel surrounding the upper substrate at the outermost edge, and the gap column spacer and the push column spacer may include the same material of the black bezel.

[0092] The liquid crystal display according to an embodiment may include a gap spacer for keeping the gap of the liquid crystal layer sandwiched between the upper substrate and the lower substrate, and a push spacer for preventing the gap of the liquid crystal layer from being severely thinned by the external pressing force. Therefore, any distortion of the display quality due to the pressing force applied on the display surface may be prevented. Further, the height difference between the gap spacer and the push spacer may be exactly designed and controlled as the color filter and the thin film transistor may be formed on one substrate and the gap and push spacers may be formed on the other substrate.

[0093] Various variations and modifications are possi-

ble in the component parts and/or arrangements of the subject combination arrangement within the scope of the appended claims.

Claims

1. A liquid crystal display device, comprising:

a lower substrate (SL),
an upper substrate (SU), and
a liquid crystal layer (LC) disposed between the lower substrate (SL) and the upper substrate (SU),

wherein the lower substrate (SL) comprises:

a plurality of pixel areas disposed in a matrix manner, the pixel areas including subpixels comprising pixel electrodes (PXL) and common electrodes (COM) each subpixel comprising a thin film transistor (T);

non-aperture areas surrounding aperture areas in the pixel areas;

a contact hole area (CA) provided within the non-aperture area of each subpixel at the vicinity of the thin film transistor (T), a contact hole (DH) connecting the thin film transistor (T) to the pixel electrode (PXL) and a common contact hole (CH) connecting the common electrode (COM) to a common line (CL) being disposed within each contact hole area (CA);

a first color filter disposed in the non-aperture area and the aperture area of a first subpixel in the pixel areas, except in the contact hole area (CA); and

a second color filter disposed in the non-aperture area and the aperture area of a second subpixel in the pixel areas, except in the contact hole area (CA);

wherein the first and the second color filter overlap in the non-aperture area;

wherein the upper substrate (SU) comprises, at said overlap areas:

gap column spacers (GCS) configured to keep the gap of the liquid crystal layer (LC) in uniform condition; and

push column spacers (PCS) separated from the lower substrate (SL) and configured to sustain the gap when a pressing force is applied to a surface of the display device.

2. The device of claim 1, wherein:

a distance between two neighboring contact hole areas (CA) is 35~50 μm; and

a push column spacer (PCS) is disposed between the two neighboring contact hole areas (CA).

3. The device of claim 1 or 2, wherein:

a surface of a gap column spacer (GCS) contacts a top inner surface of the lower substrate (SL); and
a surface of a push column spacer (PCS) is separated from the top inner surface of the lower substrate (SL) by 600 ~ 700 nm.

4. The device of claim 3, wherein:

the gap column spacer (GCS) has a first height; the push column spacer (PCS) has a second height 300 ~ 400 nm less than the first height; and
a first stacked height of a first overlap area of the first color filter and the second color filter, corresponding to the push column spacer (PCS), is 200 ~ 300 nm less than a second stacked height of a second overlap area of the first color filter and the second color filter, corresponding to the gap column spacer (GCS).

5. The device of any one of claims 1 to 4, wherein:

the lower substrate (SL) further comprises a third color filter disposed at an aperture area of a third subpixel in the pixel areas;
the first color filter comprises a red color filter;
the second color filter comprises a blue color filter; and
the third color filter comprises a green color filter.

6. The device of any one of claims 1 to 5, wherein:

the non-aperture area in a pixel area of the lower substrate (SL) comprises:

a gate line (GL) and a common line (CL) disposed in a first direction of the lower substrate (SL);
a data line (DL) disposed in a second direction of the lower substrate (SL); and
the thin film transistor (T) connected to the gate line (GL) and the data line (DL);

the aperture area in a pixel area of the lower substrate (SL) comprises:

the pixel electrode (PXL) connected to the thin film transistor (T), the pixel electrode (PXL) comprising a plurality of segments separated from each other; and
the common electrode (COM) connected to

the common line (CL), the common electrode (COM) comprising a plurality of segments parallel to each segment of the pixel electrode (PXL).

7. The device according to any one of claims 1 to 6, wherein:

the upper substrate (SU) further comprises a black bezel surrounding the upper substrate (SU) at the outermost edge; and
gap column spacers (GCS) and push column spacers (PCS) comprise a same material as the black bezel.

8. A method of manufacturing a liquid crystal display device, the method comprising:

providing a lower substrate (SL),
providing an upper substrate (SU), and
providing a liquid crystal layer (LC) disposed between the lower substrate (SL) and the upper substrate (SU),
wherein providing the lower substrate (SL) comprises:

providing a plurality of pixel areas in a matrix manner, the pixel areas including subpixels comprising pixel electrodes (PXL) and common electrodes (COM), each subpixel comprising a thin film transistor (T);
providing non-aperture areas surrounding aperture areas in the pixel areas;
providing a contact hole area (CA) within the non-aperture area of each subpixel at the vicinity of the thin film transistor (T), a contact hole (DH) connecting the thin film transistor (T) to the pixel electrode (PXL) and a common contact hole (CH) connecting the common electrode (COM) to a common line (CL) being disposed within each contact hole area (CA);
providing a first color filter in the non-aperture area and the aperture area of a first subpixel, in the pixel areas except in the contact hole area (CA); and
providing a second color filter in the non-aperture area and the aperture area of a second subpixel in the pixel areas, except in the contact hole area (CA) such that the first and the second color filter overlap in the non-aperture area;

wherein providing an upper substrate (SU) comprises, at said overlap areas:

providing gap column spacers (GCS) configured to keep the gap of the liquid crystal

layer (LC) in uniform condition; and
 providing push column spacers (PCS) separated from the lower substrate (SL) and to sustain the gap when a pressing force is applied to a surface of the display device. 5

9. The method of claim 8, wherein:

a distance between two neighboring contact hole areas (CA) is 35~50 μm ; and 10
 a push column spacer (PCS) is provided between the two neighboring contact hole areas (CA).

10. The method of claim 8 or 9, wherein: 15

a surface of a gap column spacer (GCS) is provided to contact a top inner surface of the lower substrate (SL); and
 a surface of a push column spacer (PCS) is provided to be separated from the top inner surface of the lower substrate (SL) by 600 ~ 700 nm. 20

11. The method of claim 10, wherein: 25

the gap column spacer (GCS) is provided to have a first height;
 the push column (PCS) spacer is provided to have a second height 300 ~ 400 nm less than the first height; and
 a first stacked height of a first overlap area of the first color filter and the second color filter, corresponding to a push column spacer (PCS), is provided to be 200 ~ 300 nm less than a second stacked height of a second overlap area of the first color filter and the second color filter, corresponding to a gap column spacer (GCS). 30

12. The method of any one of claims 8 to 11, wherein: 35

providing the lower substrate (SL) further comprises providing a third color filter disposed at an aperture area of a third subpixel in the pixel areas;
 providing the first color filter comprises providing a red color filter; 40
 providing the second color filter comprises providing a blue color filter; and
 providing the third color filter comprises providing a green color filter. 45

13. The method of any one of claims 8 to 12, wherein: 50

providing the non-aperture area in a pixel area of the lower substrate (SL) further comprises: 55
 providing a gate line (GL) and a common line (CL) in a first direction of the lower sub-

strate (SL);
 providing a data line (DL) in a second direction of the lower substrate (SL); and
 providing the thin film transistor (T) connected to the gate line (GL) and the data line (DL); and

providing the aperture area in a pixel area of the lower substrate (SL) further comprises:

providing the pixel electrode (PXL) with a plurality of segments separated from each other; and
 providing the common electrode (COM) with a plurality of segments parallel to each segment of the pixel electrode (PXL).

14. The method according to any one of claims 8 to 13, wherein:

providing the upper substrate (SU) further comprises providing a black bezel surrounding the upper substrate (SU) at the outermost edge; and
 gap column spacers (GCS) and push column spacers (PCS) comprise a same material as the black bezel.

Patentansprüche

1. Eine Flüssigkristall-Anzeigevorrichtung, aufweisend:

ein unteres Substrat (SL),
 ein oberes Substrat (SU), und
 eine Flüssigkristallschicht (LC), die zwischen dem unteren Substrat (SL) und dem oberen Substrat (SU) angeordnet ist,
 wobei das untere Substrat (SL) aufweist:

eine Mehrzahl von Pixelbereichen, die in einer Matrix-Form angeordnet sind, wobei die Pixelbereiche Subpixel enthalten, die Pixelelektroden (PXL) und gemeinsame Elektroden (COM) enthalten, wobei jedes Subpixel einen Dünnschicht-Transistor (T) aufweist; Nicht-Öffnungsbereiche, welche Öffnungsbereiche in den Pixelbereichen umgeben; einen Kontaktlochbereich (CA), der sich innerhalb des Nicht-Öffnungsbereichs von jedem Subpixel in der Nähe des Dünnschicht-Transistors (T) befindet, ein Kontaktloch (DH), welches den Dünnschicht-Transistor (T) mit der Pixelelektrode (PXL) verbindet, und ein gemeinsames Kontaktloch (CH), das die gemeinsame Elektrode (COM) mit einer gemeinsamen Leitung (CL) verbindet, die innerhalb von jedem Kontaktlochbe-

- reich (CA) angeordnet ist;
einen ersten Farbfilter, der im Nicht-Öffnungsbereich und im Öffnungsbereich eines ersten Subpixel in den Pixelbereichen außer im Kontaktlochbereich (CA) angeordnet ist; und
einen zweiten Farbfilter, der im Nicht-Öffnungsbereich und im Öffnungsbereich eines zweiten Subpixel in den Pixelbereichen außer im Kontaktlochbereich (CA) angeordnet ist, wobei sich der erste Farbfilter und der zweite Farbfilter auf dem Nicht-Öffnungsbereich überlappen;
- wobei das obere Substrat (SU) an den Überlappungsbereichen aufweist:
- Spaltsäulenabstandshalter (GCS), die so konfiguriert sind, dass sie den Spalt der Flüssigkristallschicht (LC) in einheitlichem Zustand halten; und
Drucksäulenabstandshalter (PCS), die vom unteren Substrat (SL) getrennt und so konfiguriert sind, dass sie den Spalt aufrechterhalten, wenn eine Presskraft auf eine Oberfläche des Anzeigegeräts ausgeübt wird.
2. Die Vorrichtung gemäß Anspruch 1, wobei:
- der Abstand zwischen zwei benachbarten Kontaktlochbereichen (CA) 35~50 μm lang ist; und
ein Drucksäulenabstandshalter (PCS) zwischen den beiden benachbarten Kontaktlochbereichen (CA) angeordnet ist.
3. Die Vorrichtung gemäß Anspruch 1 oder 2, wobei:
- eine Oberfläche eines Spaltsäulenabstandshalters (GCS) mit einer oberen inneren Oberfläche des unteren Substrats (SL) in Kontakt kommt; und
eine Oberfläche eines Drucksäulenabstandshalters (PCS) von der oberen inneren Oberfläche des unteren Substrats (SL) um 600~700 nm getrennt ist.
4. Die Vorrichtung gemäß Anspruch 3, wobei:
- der Spaltsäulenabstandshalter (GCS) eine erste Höhe besitzt;
der Drucksäulenabstandshalter (PCS) eine zweite Höhe besitzt, die um 300~400 nm kleiner als die erste Höhe ist; und
eine erste gestapelte Höhe eines ersten Überlappungsbereichs zwischen dem ersten Farbfilter und dem zweiten Farbfilter, die dem Drucksäulenabstandshalter (PCS) entspricht, um
- 200~300 nm kleiner ist als eine zweite gestapelte Höhe eines zweiten Überlappungsbereichs zwischen dem ersten Farbfilter und dem zweiten Farbfilter, die dem Spaltsäulenabstandshalter (GCS) entspricht.
5. Die Vorrichtung gemäß einem der Ansprüche 1 bis 4, wobei:
- das untere Substrat (SL) ferner einen dritten Farbfilter aufweist, der auf einem Öffnungsbereich eines dritten Subpixels in den Pixelbereichen angeordnet ist;
der erste Farbfilter einen roten Farbfilter enthält;
der zweite Farbfilter einen blauen Farbfilter enthält; und
der dritte Farbfilter einen grünen Farbfilter enthält.
6. Die Vorrichtung gemäß einem der Ansprüche 1 bis 5, wobei:
- der Nicht-Öffnungsbereich in einem Pixelbereich des unteren Substrats (SL) aufweist:
- eine Gate-Leitung (GL) und eine gemeinsame Leitung (CL), die in einer ersten Richtung des unteren Substrats (SL) angeordnet ist;
eine Datenleitung (DL) die in einer zweiten Richtung des unteren Substrats (SL) angeordnet ist; und
den Dünnschicht-Transistor (T), der mit der Gate-Leitung (GL) und der Datenleitung (DL) verbunden ist;
- der Öffnungsbereich in einem Pixelbereich des unteren Substrats (SL) aufweist:
- die Pixelelektrode (PXL), die mit dem Dünnschicht-Transistor (T) verbunden ist, wobei die Pixelelektrode (PXL) eine Mehrzahl von voneinander getrennten Segmenten aufweist; und
die gemeinsame Elektrode (COM), die mit der gemeinsamen Leitung (CL) verbunden ist, wobei die gemeinsame Elektrode (COM) eine Mehrzahl von Segmenten, die parallel zu jedem Segment der Pixelelektrode (PXL) sind, aufweist.
7. Die Vorrichtung gemäß einem der Ansprüche 1 bis 6, wobei:
- das obere Substrat (SU) ferner eine schwarze Umrandung aufweist, die das obere Substrat (SU) am äußersten Rand umgibt; und
die Spaltsäulenabstandshalter (GCS) und

Drucksäulenabstandhalter (PCS) das gleiche Material wie die schwarze Umrandung enthalten.

8. Verfahren zur Herstellung einer Flüssigkristall-Anzeigevorrichtung, umfassend:

Bereitstellen eines unteren Substrats (SL),
Bereitstellen eines oberen Substrats (SU), und
Bereitstellen einer Flüssigkristallschicht (LC),
die zwischen dem unteren Substrat (SL) und
dem oberen Substrat (SU) angeordnet ist,
wobei das Bereitstellen des unteren Substrats
(SL) umfasst:

Bereitstellen einer Mehrzahl von Pixelbereichen,
die in einer Matrix-Form angeordnet
sind, wobei die Pixelbereiche Subpixel enthalten,
die Pixelelektroden (PXL) und gemeinsame
Elektroden (COM) enthalten,
wobei jedes Subpixel einen Dünnschicht-
Transistor (T) aufweist;

Bereitstellen von Nicht-Öffnungsbereichen,
welche Öffnungsbereiche in den Pixelbereichen
umgeben;

Bereitstellen eines Kontaktlochbereichs
(CA), der sich innerhalb des Nicht-Öffnungsbereichs
von jedem Subpixel in der Nähe des Dünnschicht-
Transistors (T) befindet, eines Kontaktloches (DH),
welches den Dünnschicht-Transistor (T) mit der
Pixelelektrode (PXL) verbindet, und eines gemeinsamen
Kontaktlochs (CH), das die gemeinsame Elektrode
(COM) mit einer gemeinsamen Leitung (CL) verbindet,
die innerhalb von jedem Kontaktlochbereich
(CA) angeordnet ist;

Bereitstellen eines ersten Farbfilters, der im
Nicht-Öffnungsbereich und im Öffnungsbereich
eines ersten Subpixel in den Pixelbereichen außer
im Kontaktlochbereich (CA) angeordnet ist; und

Bereitstellen eines zweiten Farbfilters, der
im Nicht-Öffnungsbereich und im Öffnungsbereich
eines zweiten Subpixel in den Pixelbereichen außer
im Kontaktlochbereich (CA) angeordnet ist, wobei
sich der erste Farbfilter und der zweite Farbfilter
auf dem Nicht-Öffnungsbereich überlappen;

wobei das Bereitstellen des oberen Substrats
(SU) an den Überlappungsbereichen umfasst:

Bereitstellen von Spaltsäulenabstandhal-
tern (GCS), die so konfiguriert sind, dass
sie den Spalt der Flüssigkristallschicht (LC)
in einheitlichem Zustand halten; und
Bereitstellen von Drucksäulenabstandhal-

tern (PCS), die vom unteren Substrat (SL)
getrennt und zum Aufrechterhalten des
Spaltes sind, wenn eine Presskraft auf eine
Oberfläche des Anzeigegeräts ausgeübt
wird.

9. Verfahren gemäß Anspruch 8, wobei:

der Abstand zwischen zwei benachbarten Kon-
taktlochbereichen (CA) 35~50 μm lang ist; und
ein Drucksäulenabstandhalter (PCS) zwischen
den beiden benachbarten Kontaktlochbereichen
(CA) bereitgestellt ist.

10. Verfahren gemäß Anspruch 8 oder 9, wobei:

eine Oberfläche eines Spaltsäulenabstandshal-
ters (GCS) bereitgestellt wird, welche mit einer
oberen inneren Oberfläche des unteren Subst-
rats (SL) in Kontakt kommt; und
eine Oberfläche eines Drucksäulenabstandshal-
ters (PCS) bereitgestellt wird, welche von der
oberen inneren Oberfläche des unteren Subst-
rats (SL) um 600~700 nm getrennt ist.

11. Verfahren gemäß Anspruch 10, wobei:

der Spaltsäulenabstandhalter (GCS) bereitge-
stellt ist eine erste Höhe zu besitzen;
der Drucksäulenabstandhalter (PCS) bereitge-
stellt ist eine zweite Höhe zu besitzen, die um
300~400 nm kleiner als die erste Höhe ist; und
eine erste gestapelte Höhe eines ersten Über-
lappungsbereichs zwischen dem ersten Farbfil-
ter und dem zweiten Farbfilter bereitgestellt ist,
die dem Drucksäulenabstandhalter (PCS) ent-
spricht, welche um 200~300 nm kleiner ist als
eine zweite gestapelte Höhe eines zweiten
Überlappungsbereichs zwischen dem ersten
Farbfilter und dem zweiten Farbfilter, die dem
Spaltsäulenabstandhalter (GCS) entspricht.

12. Verfahren gemäß einem der Ansprüche 8 bis 11,
wobei:

das Bereitstellen des unteren Substrats (SL) fer-
ner das Bereitstellen eines dritten Farbfilters
aufweist, der auf einem Öffnungsbereich eines
dritten Subpixels in den Pixelbereichen ange-
ordnet ist;
das Bereitstellen des ersten Farbfilters das Be-
reitstellen eines roten Farbfilters enthält;
das Bereitstellen des zweiten Farbfilters das Be-
reitstellen eines blauen Farbfilters enthält; und
das Bereitstellen des dritten Farbfilters das Be-
reitstellen eines grünen Farbfilters enthält.

13. Verfahren gemäß einem der Ansprüche 8 bis 12,

wobei:

das Bereitstellen des Nicht-Öffnungsbereichs in einem Pixelbereich des unteren Substrats (SL) ferner aufweist:

5

Bereitstellen einer Gate-Leitung (GL) und einer gemeinsamen Leitung (CL), die in einer ersten Richtung des unteren Substrats (SL) angeordnet ist;

10

Bereitstellen einer Datenleitung (DL) die in einer zweiten Richtung des unteren Substrats (SL) angeordnet ist; und

Bereitstellen des Dünnschicht-Transistors (T), der mit der Gate-Leitung (GL) und der Datenleitung (DL) verbunden ist; und

15

das Bereitstellen des Öffnungsbereichs in einem Pixelbereich des unteren Substrats (SL) ferner aufweist:

20

Bereitstellen der Pixelelektrode (PXL), die mit dem Dünnschicht-Transistor (T) verbunden ist, wobei die Pixelelektrode (PXL) eine Mehrzahl von voneinander getrennten Segmenten aufweist; und

25

Bereitstellen der gemeinsamen Elektrode (COM), die mit der gemeinsamen Leitung (CL) verbunden ist, wobei die gemeinsame Elektrode (COM) eine Mehrzahl von Segmenten, die parallel zu jedem Segment der Pixelelektrode (PXL) sind, aufweist.

30

14. Verfahren gemäß einem der Ansprüche 8 bis 13, wobei:

35

das Bereitstellen des oberen Substrats (SU) ferner eine schwarze Umrandung aufweist, die das obere Substrat (SU) am äußersten Rand umgibt; und

40

die Spaltsäulenabstandshalter (GCS) und Drucksäulenabstandshalter (PCS) das gleiche Material wie die schwarze Umrandung enthalten.

45

Revendications

1. Dispositif d'affichage à cristaux liquides, comprenant :

50

un substrat inférieur (SL) ;

un substrat supérieur (SU) ; et

une couche de cristaux liquides (LC) disposée entre le substrat inférieur (SL) et le substrat supérieur (SU) ;

55

dans lequel le substrat inférieur (SL) comprend :

une pluralité de zones de pixels disposées à la façon d'une matrice, les zones de pixels comprenant des pixels secondaires, qui comprennent des électrodes de pixels (PXL) et des électrodes communes (COM), chaque pixel secondaire comprenant un transistor à couches minces (T) ;

des zones de non ouverture qui entourent des zones d'ouverture dans les zones de pixels ;

une zone de trou de contact (CA) disposée à l'intérieur de la zone de non ouverture de chaque pixel secondaire à proximité du transistor à couches minces (T), un trou de contact (DH) connectant le transistor à couches minces (T) à l'électrode de pixels (PXL), et un trou de contact commun (CH) connectant l'électrode commune (COM) à une ligne commune (CL) disposée à l'intérieur de chaque zone de trou de contact (CA) ;

un premier filtre de couleur disposé dans la zone de non ouverture et dans la zone d'ouverture d'un premier pixel secondaire dans les zones de pixels, à l'exception de l'intérieur de la zone de trou de contact (CA) ; et

un deuxième filtre de couleur disposé dans la zone de non ouverture et dans la zone d'ouverture d'un deuxième pixel secondaire dans les zones de pixels, à l'exception de l'intérieur de la zone de trou de contact (CA) ;

dans lequel les premier et deuxième filtres de couleur se chevauchent dans la zone de non ouverture ;

dans lequel le substrat supérieur (SU) comprend, au niveau desdites zones de chevauchement :

des dispositifs d'espacement de colonne d'espace (GCS) configurés de façon à maintenir l'espace de la couche de cristaux liquides (LC) dans un état uniforme ; et des dispositifs d'espacement de colonne de poussée (PCS) séparés du substrat inférieur (SL) et configurés de façon à maintenir l'espace quand une force de pression est appliquée sur la surface du dispositif d'affichage.

2. Dispositif selon la revendication 1, dans lequel :

la distance entre deux zones de trou de contact voisines (CA) est comprise entre 35 μm ~ 50 μm ; et

un dispositif d'espacement de colonne de pous-

- sée (PCS) est disposé entre les deux zones de trou de contact voisines (CA).
3. Dispositif selon la revendication 1 ou la revendication 2, dans lequel :
- la surface d'un dispositif d'espacement de colonne d'espace (GCS) entre en contact avec la surface intérieure supérieure du substrat inférieur (SL) ; et
 - la surface d'un dispositif d'espacement de colonne de poussée (PCS) est séparée de la surface intérieure supérieure du substrat inférieur (SL) d'une distance comprise entre 600 nm ~ 700 nm.
4. Dispositif selon la revendication 3, dans lequel :
- le dispositif d'espacement de colonne d'espace (GCS) présente une première hauteur ;
 - le dispositif d'espacement de colonne de poussée (PCS) présente une seconde hauteur de 300 nm ~ 400 nm inférieure à la première hauteur ; et
 - une première hauteur empilée d'une première zone de chevauchement du premier filtre de couleur et du deuxième filtre de couleur, correspondant au dispositif d'espacement de colonne de poussée (PCS), est de 200 nm ~ 300 nm inférieure à une seconde hauteur empilée d'une deuxième zone de superposition du premier filtre de couleur et du deuxième filtre de couleur, correspondant au dispositif d'espacement de colonne d'espace (GCS).
5. Dispositif selon l'une quelconque des revendications 1 à 4, dans lequel :
- le substrat inférieur (SL) comprend en outre un troisième filtre de couleur disposé au niveau d'une zone d'ouverture d'un troisième pixel secondaire dans les zones de pixels ;
 - le premier filtre de couleur comprend un filtre de couleur rouge ;
 - le deuxième filtre de couleur comprend un filtre de couleur bleue ; et
 - le troisième filtre de couleur comprend un filtre de couleur verte.
6. Dispositif selon l'une quelconque des revendications 1 à 5, dans lequel :
- la zone de non ouverture dans une zone de pixel du substrat inférieur (SL) comprend :
 - une ligne de grille (GL) et une ligne commune (CL) disposées dans une première direction du substrat inférieur (SL) ;
- une ligne de données (DL) disposée dans une seconde direction du substrat inférieur (SL) ;
- et le transistor à couches minces (T) connecté à la ligne de grille (GL) et à la ligne de données (DL) ;
- la zone d'ouverture dans une zone de pixel du substrat inférieur (SL) comprend :
- l'électrode de pixels (PXL) connectée au transistor à couches minces (T), l'électrode de pixels (PXL) comprenant une pluralité de segments séparés les uns des autres ; et
 - l'électrode commune (COM) connectée à la ligne commune (CL), l'électrode commune (COM) comprenant une pluralité de segments parallèles à chaque segment de l'électrode de pixels (PXL).
7. Dispositif selon l'une quelconque des revendications 1 à 6, dans lequel :
- le substrat supérieur (SU) comprend en outre un encadrement noir qui entoure le substrat supérieur (SU) au niveau du bord le plus extérieur ; et
 - les dispositifs d'espacement de colonne d'espace (GCS) et les dispositifs d'espacement de colonne de poussée (PCS) comprennent le même matériau que celui de l'encadrement noir.
8. Procédé destiné à fabriquer un dispositif d'affichage à cristaux liquides, le procédé comprenant les étapes consistant à :
- fournir un substrat inférieur (SL) ;
 - fournir un substrat supérieur (SU) ; et
 - fournir une couche de cristaux liquides (LC) disposée entre le substrat inférieur (SL) et le substrat supérieur (SU) ;
- dans lequel l'étape consistant à fournir le substrat inférieur (SL) comprend les étapes consistant à :
- fournir une pluralité de zones de pixels à la façon d'une matrice, les zones de pixels comprenant des pixels secondaires, qui comprennent des électrodes de pixels (PXL) et des électrodes communes (COM), chaque pixel secondaire comprenant un transistor à couches minces (T) ;
 - fournir des zones de non ouverture qui entourent des zones d'ouverture dans les zones de pixels ;
 - fournir une zone de trou de contact (CA) à l'intérieur de la zone de non ouverture de chaque pixel secondaire à proximité du

transistor à couches minces (T), un trou de contact (DH) connectant le transistor à couches minces (T) à l'électrode de pixels (PXL), et un trou de contact commun (CH) connectant l'électrode commune (COM) à une ligne commune (CL) disposée à l'intérieur de chaque zone de trou de contact (CA) ;

fournir un premier filtre de couleur dans la zone de non ouverture et dans la zone d'ouverture d'un premier pixel secondaire dans les zones de pixels, à l'exception de l'intérieur de la zone de trou de contact (CA) ; et

fournir un deuxième filtre de couleur dans la zone de non ouverture et dans la zone d'ouverture d'un deuxième pixel secondaire dans les zones de pixels, à l'exception de l'intérieur de la zone de trou de contact (CA), de telle sorte que les premier et deuxième filtres de couleur se chevauchent dans la zone de non ouverture ;

dans lequel l'étape consistant à fournir le substrat supérieur (SU) comprend, au niveau des dites zones de chevauchement, les étapes consistant à :

fournir des dispositifs d'espacement de colonne d'espace (GCS) configurés de façon à maintenir l'espace de la couche de cristaux liquides (LC) dans un état uniforme ; et fournir des dispositifs d'espacement de colonne de poussée (PCS) séparés du substrat inférieur (SL) et configurés de façon à maintenir l'espace quand une force de pression est appliquée sur la surface du dispositif d'affichage.

9. Procédé selon la revendication 8, dans lequel :

la distance entre deux zones de trou de contact voisines (CA) est comprise entre 35 μm et 50 μm ; et un dispositif d'espacement de colonne de poussée (PCS) est disposé entre les deux zones de trou de contact voisines (CA).

10. Procédé selon la revendication 8 ou la revendication 9, dans lequel :

la surface d'un dispositif d'espacement de colonne d'espace (GCS) est prévue de façon à entrer en contact avec la surface intérieure supérieure du substrat inférieur (SL) ; et la surface d'un dispositif d'espacement de colonne de poussée (PCS) est prévue de façon à être séparée de la surface intérieure supérieure

du substrat inférieur (SL) d'une distance comprise entre 600 nm ~ 700 nm.

11. Procédé selon la revendication 10, dans lequel :

le dispositif d'espacement de colonne d'espace (GCS) est prévu de façon à présenter une première hauteur ;

le dispositif d'espacement de colonne de poussée (PCS) est prévu de façon à présenter une seconde hauteur de 300 nm ~ 400 nm inférieure à la première hauteur ; et

une première hauteur empilée d'une première zone de chevauchement du premier filtre de couleur et du deuxième filtre de couleur, correspondant à un dispositif d'espacement de colonne de poussée (PCS), est prévue de façon à être égale à 200 nm ~ 300 nm inférieure à une seconde hauteur empilée d'une deuxième zone de superposition du premier filtre de couleur et du deuxième filtre de couleur, correspondant à un dispositif d'espacement de colonne d'espace (GCS).

12. Procédé selon l'une quelconque des revendications 8 à 11, dans lequel :

l'étape consistant à fournir le substrat inférieur (SL) comprend en outre une étape consistant à fournir un troisième filtre de couleur disposé au niveau d'une zone d'ouverture d'un troisième pixel secondaire dans les zones de pixels ; l'étape consistant à fournir le premier filtre de couleur comprend une étape consistant à fournir un filtre de couleur rouge ; l'étape consistant à fournir le deuxième filtre de couleur comprend une étape consistant à fournir un filtre de couleur bleue ; et l'étape consistant à fournir le troisième filtre de couleur comprend une étape consistant à fournir un filtre de couleur verte.

13. Procédé selon l'une quelconque des revendications 8 à 12, dans lequel :

l'étape consistant à fournir la zone de non ouverture dans une zone de pixel du substrat inférieur (SL) comprend en outre les étapes consistant à :

fournir une ligne de grille (GL) et une ligne commune (CL) dans une première direction du substrat inférieur (SL) ; fournir une ligne de données (DL) dans une seconde direction du substrat inférieur (SL) ; et fournir le transistor à couches minces (T) connecté à la ligne de grille (GL) et à la ligne de données (DL) ; et

l'étape consistant à fournir la zone d'ouverture dans une zone de pixel du substrat inférieur (SL) comprend en outre les étapes consistant à :

- doter l'électrode de pixels (PXL) d'une pluralité de segments séparés les uns des autres ; et 5
- doter l'électrode commune (COM) d'une pluralité de segments parallèles à chaque segment de l'électrode de pixels (PXL). 10

14. Procédé selon l'une quelconque des revendications 8 à 13, dans lequel :

- l'étape consistant à fournir le substrat supérieur (SU) comprend en outre une étape consistant à fournir un encadrement noir qui entoure le substrat supérieur (SU) au niveau du bord le plus extérieur ; et 15
- les dispositifs d'espacement de colonne d'espace (GCS) et les dispositifs d'espacement de colonne de poussée (PCS) comprennent le même matériau que celui de l'encadrement noir. 20

25

30

35

40

45

50

55

FIG. 1
Related Art

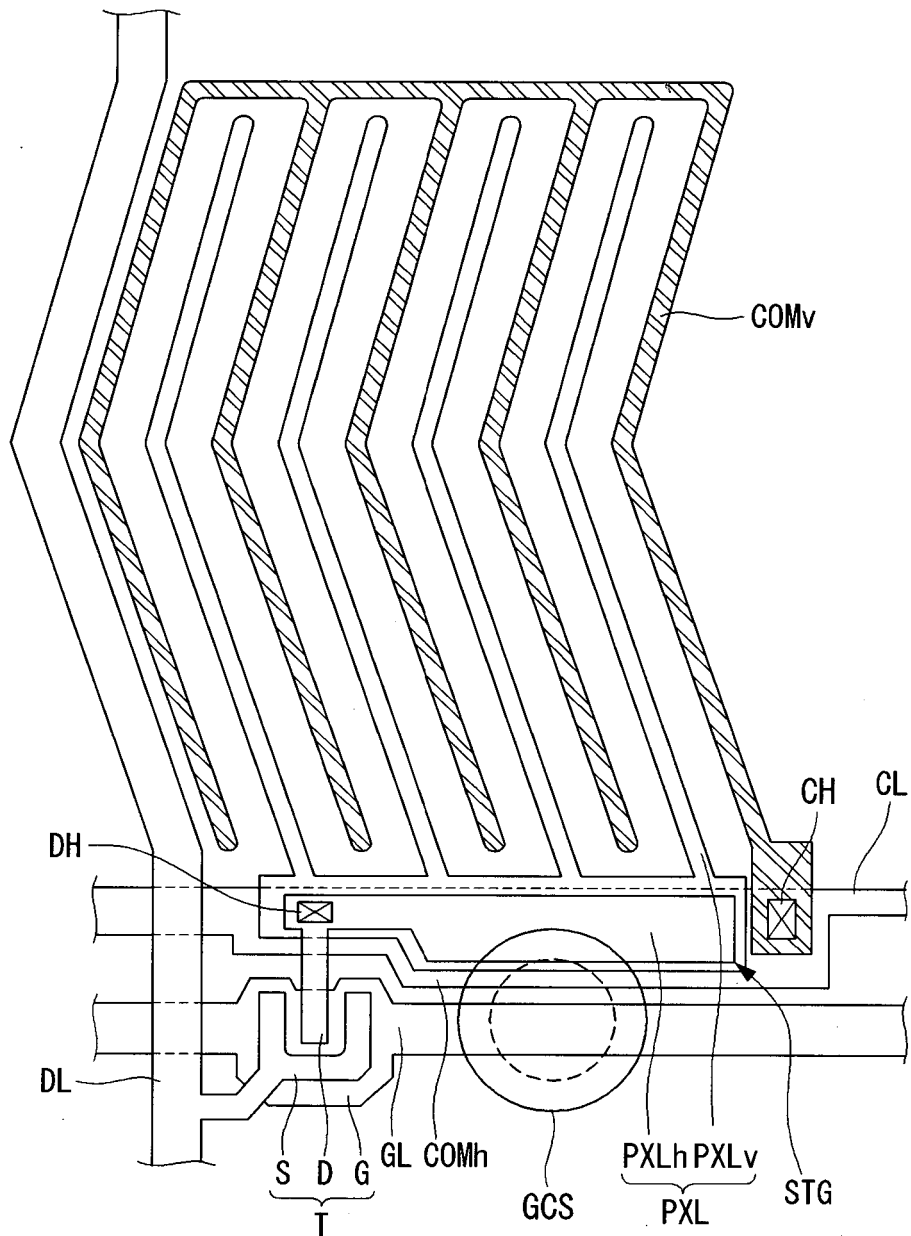


FIG. 2
Related Art

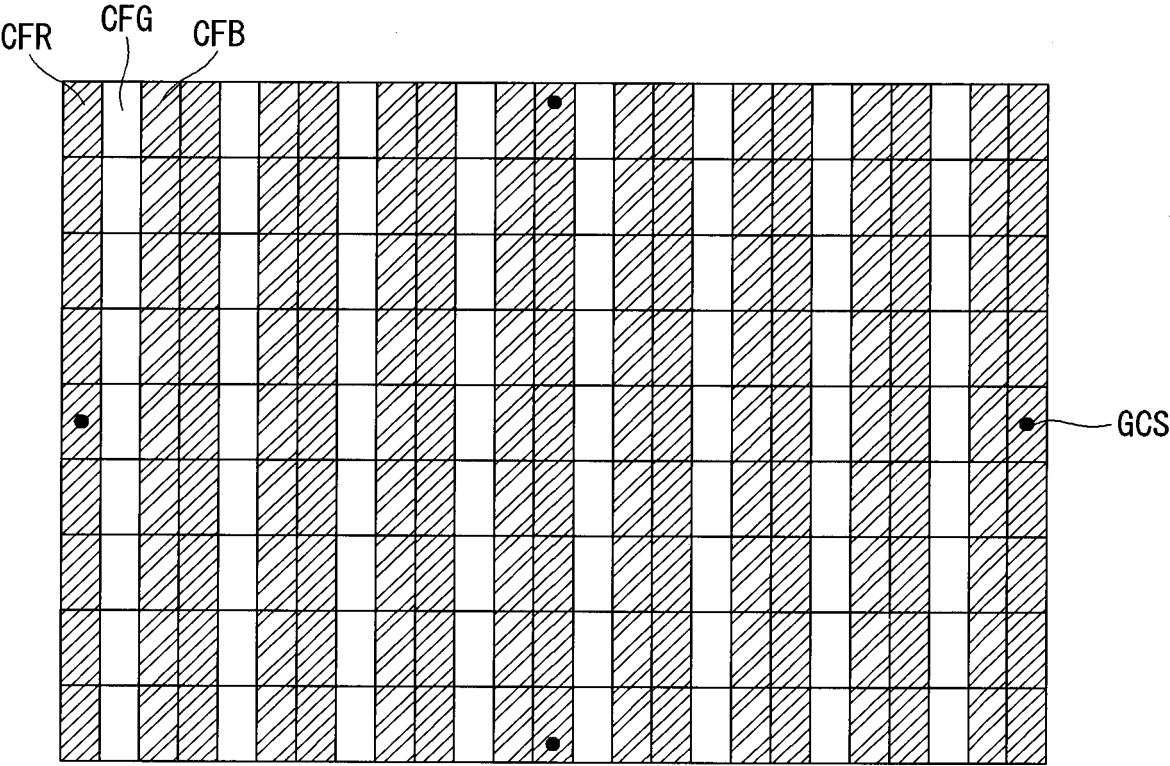


FIG. 3

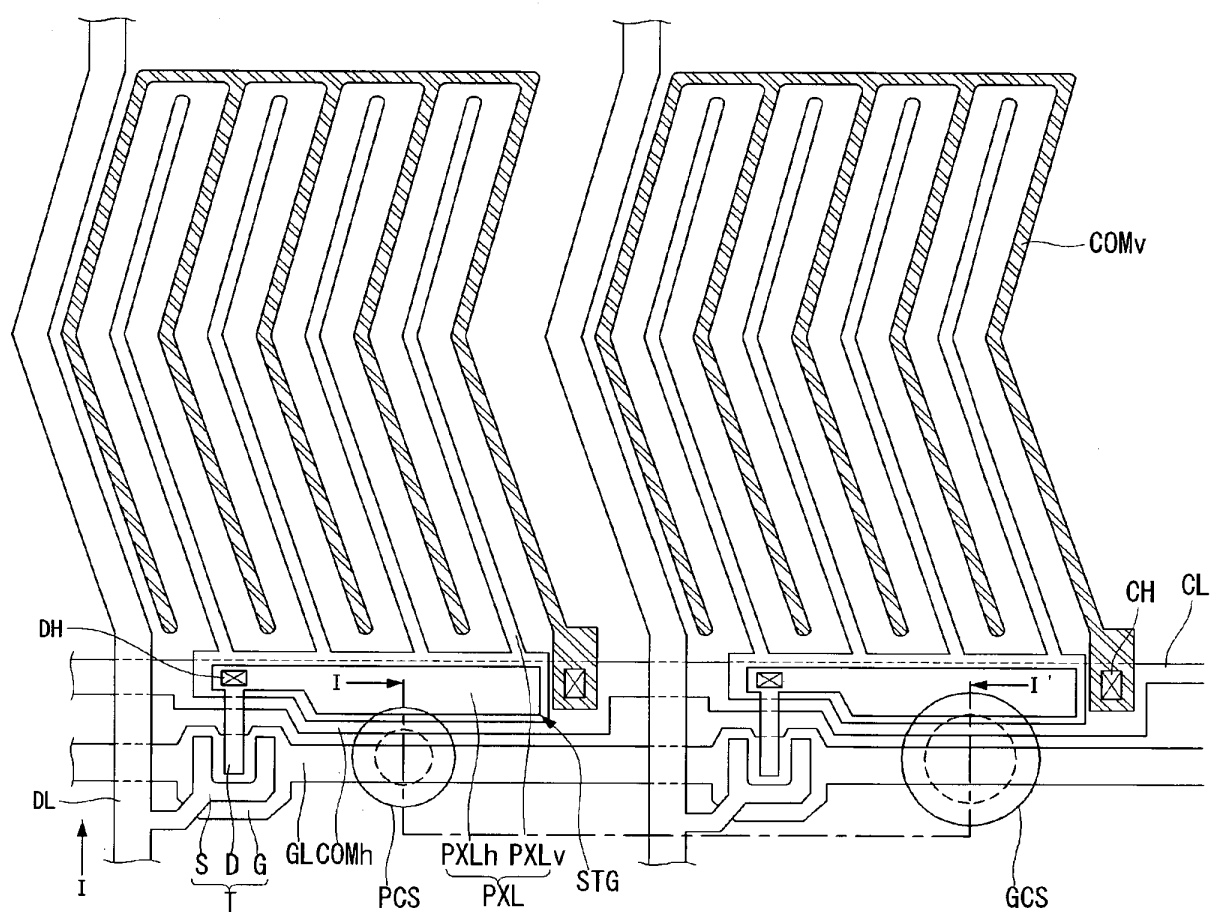


FIG. 4

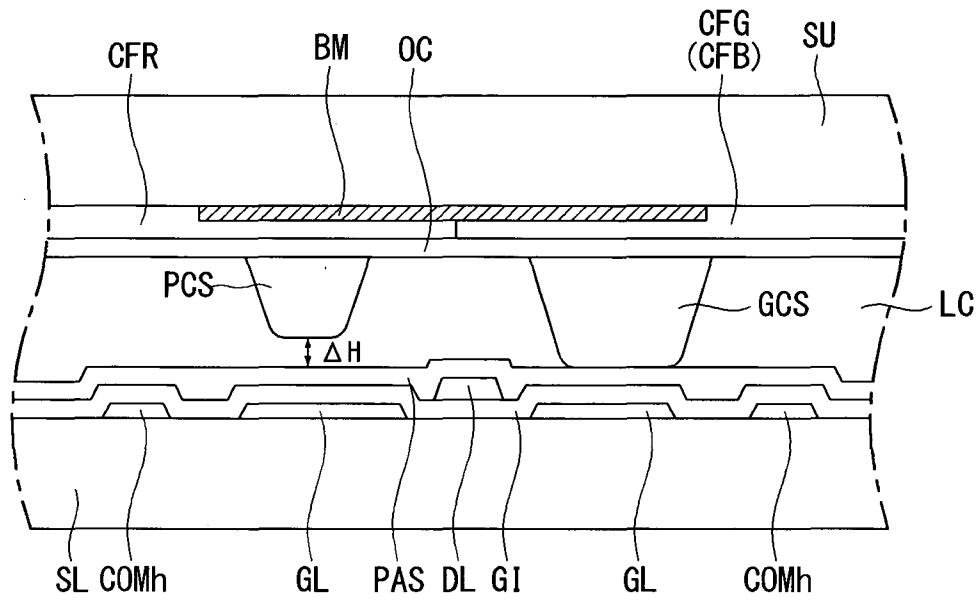


FIG. 5

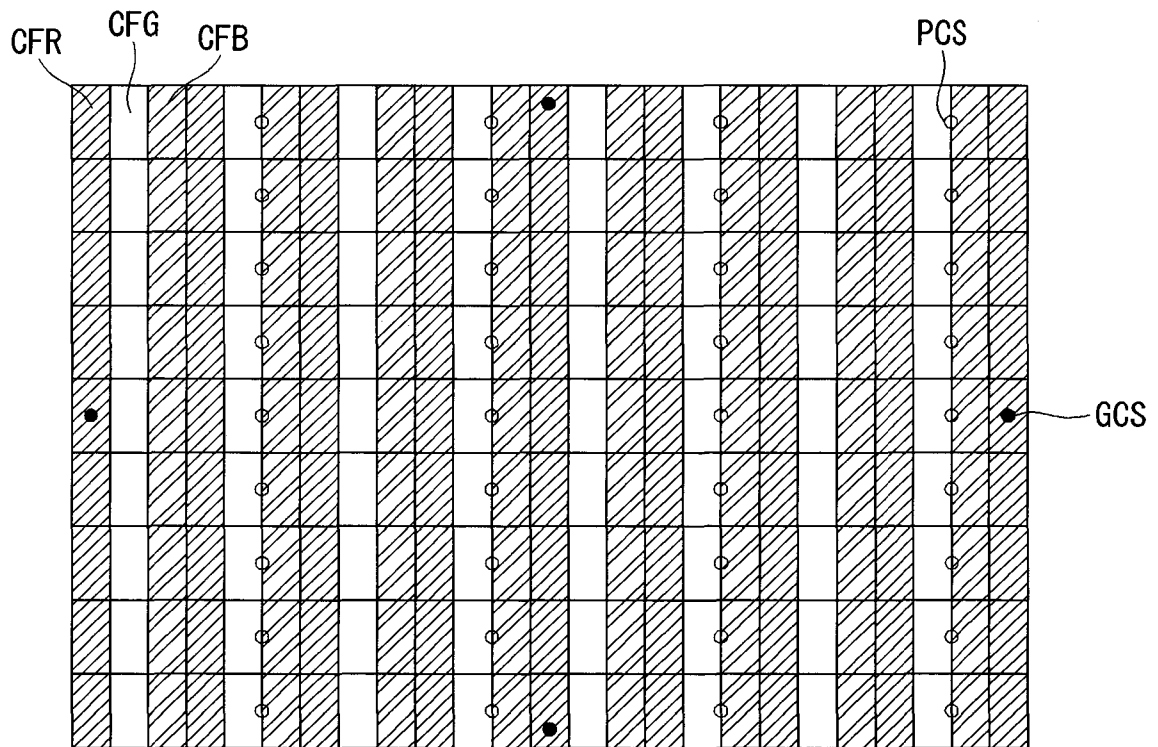


FIG. 6

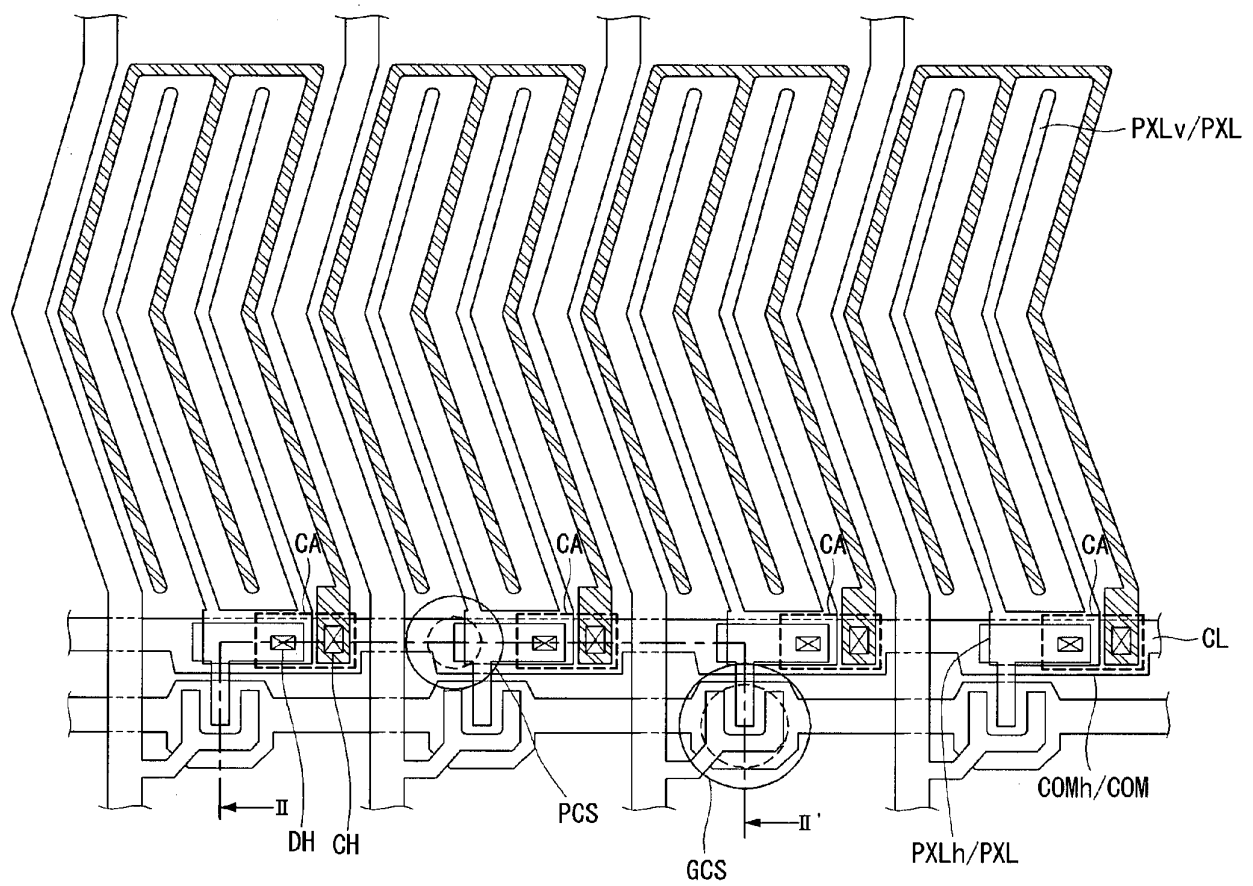


FIG. 7

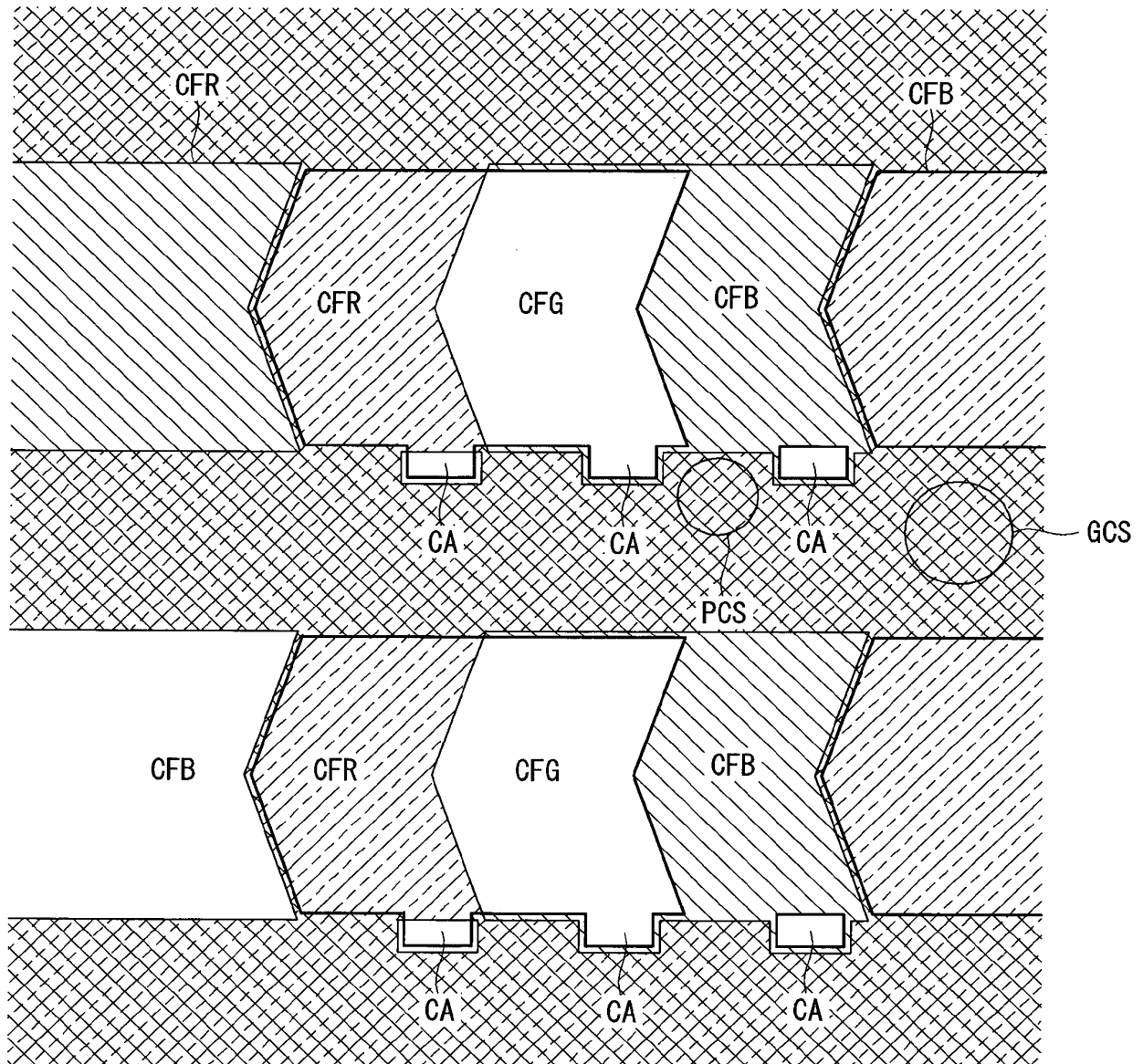
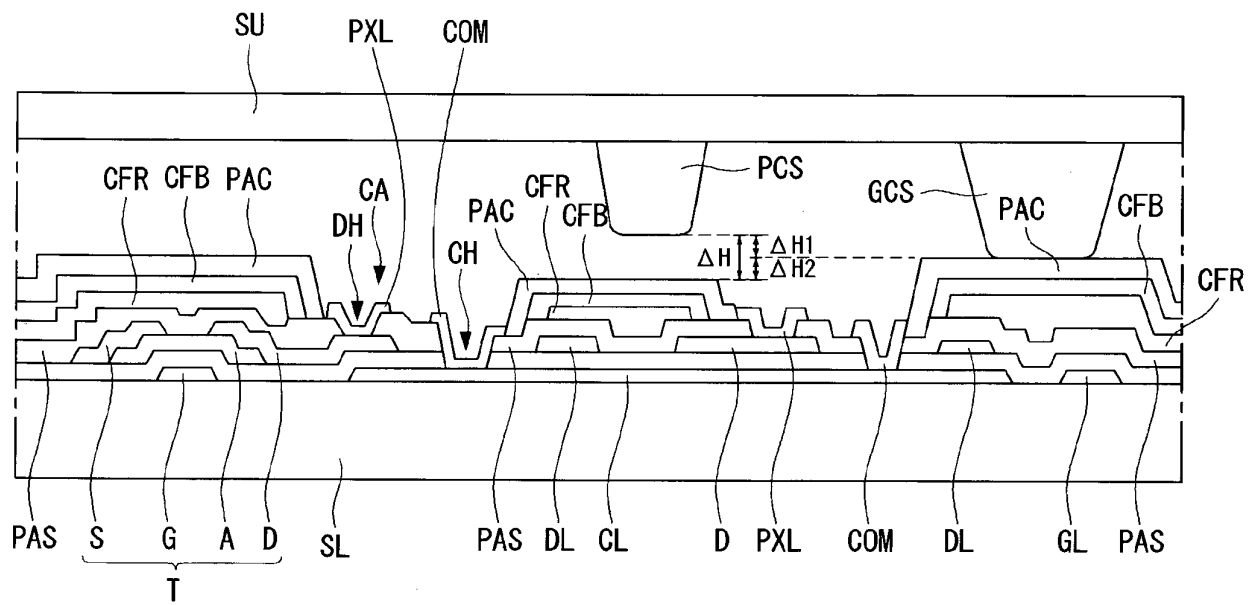


FIG. 8



REFERENCES CITED IN THE DESCRIPTION

This list of references cited by the applicant is for the reader's convenience only. It does not form part of the European patent document. Even though great care has been taken in compiling the references, errors or omissions cannot be excluded and the EPO disclaims all liability in this regard.

Patent documents cited in the description

- KR 1020130168607 [0001]
- US 20120081640 A1 [0018]
- US 20090231522 A1 [0019]
- US 20070069204 A1 [0020]
- KR 1020130062123 [0021]

专利名称(译)	具有间隙隔离物和推动隔离物的液晶显示装置及其制造方法		
公开(公告)号	EP2889679B1	公开(公告)日	2017-11-29
申请号	EP2014169957	申请日	2014-05-27
[标]申请(专利权)人(译)	乐金显示有限公司		
申请(专利权)人(译)	LG DISPLAY CO. , LTD.		
当前申请(专利权)人(译)	LG DISPLAY CO. , LTD.		
[标]发明人	CHOI HYONGJONG JO YOUNGJIK		
发明人	CHOI, HYONGJONG JO, YOUNGJIK		
IPC分类号	G02F1/1339 G02F1/1335		
CPC分类号	G02F1/134363 G02F1/133512 G02F1/133514 G02F1/13394 G02F1/134336 G02F1/136227 G02F1/136286 G02F1/1368 G02F2001/133519 G02F2001/13396 G02F2001/136222		
优先权	1020130168607 2013-12-31 KR		
其他公开文献	EP2889679A1		
外部链接	Espacenet		

摘要(译)

本发明提供一种具有间隙隔离物和推动隔离物的液晶显示 (LCD) 装置及其制造方法。液晶显示装置包括：下基板，包括：以矩阵方式设置的多个像素区域，围绕至少一个像素区域的非开口区域，由非开口区域围绕的开口区域，a非开口区域内的接触孔区域，设置在非开口区域上的第一滤色器和除接触区域之外的第一子像素的开口区域，以及设置在非开口区域上的第二滤色器和除了接触区域之外，第二子像素的开口面积，包括非开口区域的上基板：间隙柱间隔物和推柱间隔物，以及设置在下基板和上基板之间的液晶层。

FIG. 1
Related Art

